AMENDMENTS TO THE CLAIMS

(original) An imaging apparatus comprising:
 a first set of diffractive light modulators along a column of a light modulator array;
 and

a second set of diffractive light modulators along a row of the light modulator array, the diffractive light modulators in the second set being arranged such that optically active areas along the row are spaced apart.

- 2. (original) The apparatus of claim 1 wherein the diffractive light modulators in the first set and the second set comprise ribbon light modulators.
- 3. (original) The apparatus of claim 1 further comprising:
 a light source configured to shine a light beam onto the light modulator array, the light modulator array being configured to modulate the light beam on to a substrate.
- 4. (original) The apparatus of claim 3 further comprising a projection lens over the substrate.
- 5. (original) The apparatus of claim 1 further comprising a microlens array and wherein the light modulator array and the microlens array are in a same integrated packaging.
- 6. (original) The apparatus of claim 1 wherein a spacing between diffractive light modulators in the first set is different from a spacing between diffractive light modulators in the second set.
- 7. (original) The apparatus of claim 1 wherein a spacing between diffractive light modulators in the first set is substantially the same as a spacing between diffractive light modulators in the second set.
- 8. (original) The apparatus of claim 1 wherein optically active areas in the light modulator array have a repeating pattern.
- 9. (original) The apparatus of claim 8 wherein the repeating pattern comprises a rectangular pattern.
- 10. (original) The apparatus of claim 1 wherein diffractive light modulators in the second set have a pitch that is at least twice the size of an optically active area of a diffractive light modulator in the light modulator array.
- 11-15 (canceled)

Docket No. 10021.002310 (P0307) Response To Office Action January 31, 2005

- 16. (original) A lithography system comprising:
- a light modulator array comprising a plurality of diffractive light modulators arranged in columns, the diffractive light modulators within the columns having a first pitch and the columns being spaced according to a second pitch; and
- a lens configured to project modulated light from the light modulator onto a substrate being patterned.
- 17. (original) The lithography system of claim 16 wherein the first pitch is greater than the second pitch.
- 18. (original) The lithography system of claim 16 wherein the first pitch is at least two times the size of an optically active area of a diffractive light modulator in the light modulator array.
- 19. (original) The lithography system of claim 16 wherein the first pitch is substantially the same as the second pitch.
- 20. (original) The lithography system of claim 16 further comprising a microlens array in a same packaging as the light modulator array.